



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Akihiko OTOGURO et al.**

Group Art Unit: 1752

Serial No.: 10/092,310

Examiner: **Amanda C. Walke**

Filed: **March 7, 2002**

Confirmation No.: 8414

For: **MULTI-LAYERED RESIST STRUCTURE AND MANUFACTURING  
METHOD OF SEMICONDUCTOR DEVICE**

Attorney Docket Number: 020201

Customer Number: 38834

**AMENDMENT UNDER 37 CFR § 1.116**

**Mail Stop AF**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

November 15, 2004

Sir:

In response to the Office Action dated August 25, 2004, applicants amend the above-identified application as follows and submit the following remarks.

Amendments to the Claims are reflected in the listing of claims that begins on page 2 of this paper.

Remarks/Arguments begin on page 8 of this paper.

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